Supplementary Information

Degradation of reactive black 5 via Cu(II)/NaIO₄ advanced oxidation process: response surface methodology optimization, kinetic simulation and performance enhancement

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1 Texts

Text S1. Materials

Sodium sulfate (Na₂O₄S, 99%), and sodium bicarbonate (NaHCO₃, 99.8%) were sourced from Shanghai Een Chemical Technology Co. Phenol (C₆H₆O, 99%) was obtained from Shanghai Aladdin Biochemical Technology Co. Sodium chloride (NaCl, 99%), sodium carbonate (Na₂CO₃, 99%), and sodium nitrate (NaNO₃, 99%) was supplied by Sinopharm Chemical Reagent Co. Sodium hydroxide (NaOH, 99%) and hydrochloric acid (HCl, 99.5%) were procured from Kunshan Jincheng Reagent Co. Tert-butanol (C₄H₁₀O, 99.5%), furfuryl alcohol (C₅H₆O₂, 95%), p-benzoquinone (C₆H₄O₂, 97%), sodium dihydrogen phosphate (NaH₂PO₄, 99.9%), and humic acid (FA \geq 90%) were acquired from Shanghai McLean Biochemical Technology Co.

Text S2. Comparative analysis of various systems for degrading RB5

As shown in Fig. S1(a), the degradation of RB5 by a single SPI system and single Cu(II) system was poor with only 6.71% and 18.63% removal in 120 minutes, respectively. This indicates that SPI has a very weak oxidizing ability on RB5 in the system without the addition of a catalyst. Compared with SPI, Cu(II) has a slightly better effect on RB5 removal, which may be due to the oxidizing or adsorbing effect of Cu(II) on RB5. However, when Cu(II) and SPI coexisted in the system, the reaction was significantly accelerated, and the removal rate of RB5 within 120 minutes could reach 92.39%. This phenomenon may be assigned to the activation of SPI by Cu(II), i.e., the Cu(II)/SPI system is capable of generating a large number of ROS with strong oxidative capacity, and these substances directly oxidize RB5.¹ Additionally, the decomposition of RB5 by Cu(II)/SPI system conformed to the pseudo-first-order kinetic model with the rate constant $k_{\rm obs} = 0.0224$ min-1 and the correlation coefficient $R^2 = 0.9906$, as indicated in Fig. S1(b).

Text S3. Influence of important parameters

Effect of initial Cu(II) concentration on RB5 degradation

Fig. S2(a) gives the degradation efficiency of RB5 under various Cu(II) concentrations. The trends of the curves demonstrated a pronounced enhancement from 6.71% to 86.57% in RB5 removal efficiency as Cu(II) concentration elevated from 0 g L⁻¹ to 1 g L⁻¹. Kinetic studies revealed that the RB5 degradation consistently followed pseudo-first-order kinetics in varying initial Cu(II) concentrations. As presented in Table S1, the k_{obs} values exhibited an upward trend as the initial Cu(II) concentration rose from 0 g L⁻¹ to 1 g L⁻¹, specifically reaching 0.0008 min⁻¹, 0.0125 min⁻¹, 0.0135 min⁻¹, 0.0159 min⁻¹, and 0.0173 min⁻¹. This suggests that the capacity of degrading RB5 was progressively enhanced with the increasing initial Cu(II) concentration. The underlying reason might be that a higher Cu(II) concentration augments the number of active sites on the Cu(II) surface for IO4- activation, thereby making more ROS available to break down RB5 and consequently improving the degradation efficiency of RB5 (Eqs. S1-S2).² A distinct trend was observed as the Cu(II) concentration doubled from 1 g L⁻¹ to 2 g L⁻¹, where the RB5 degradation performance exhibited a marginal decline rather than enhancement, with negligible variation in the observed k_{obs}. This phenomenon might stem from competitive coordination chemistry, where surplus Cu(II) ions potentially formed colored metal-organic complexes with RB5 molecules (possibly azo metallated intermediates), thereby altering the reaction pathway and optical properties of the solution, ultimately affecting the apparent

decolorization efficiency.³

$$Cu^{2+} + IO_4^{-} \to Cu^{3+} + IO_3^{-}$$
 (S1)

$$Cu^{2+} + IO_4^- + H_2O \rightarrow Cu^{3+} + IO_3^- + O_2^{\bullet-} + 2H^+$$
 (S2)

Effect of initial SPI concentration on RB5 degradation

The correlation between SPI dosage and RB5 decolorization efficiency demonstrates a non-monotonic behavior as illustrated in Fig. S2(b). It revealed that an initial improvement phase in RB5 decomposition succeeded by a gradual decline when SPI concentrations exceeded 50 µM, with complete degradation performance decreasing from 92.39% to 86.57% as concentrations reached 100 µM. Kinetic analysis (Table S1) confirmed pseudo-first-order reaction patterns across tested concentrations, where the observed k_{obs} exhibited a similar trend-increasing 8.96-fold from 0.0025 min⁻¹ to 0.0224 min⁻¹ within the 0-50 μM SPI range, then decreasing to 0.0173 min⁻¹ at 100 μM. This concentration-dependent behavior is attributed to dual mechanisms: Enhanced IO₄⁻ availability at moderate SPI levels (≤50 µM) promotes efficient radical formation (IO₃⁻¹ transformation and ROS generation via Eqs. S3-S6), while excessive SPI concentrations (>50 µM) likely induce radical scavenging effects. The optimal catalytic performance at 50 µM SPI corresponds to a critical balance between oxidant generation and consumption pathways within the reaction system. This could be due to the occurrence of reverse and side reactions within the advanced oxidation system, as well as the significant impact of the high initial oxidant concentration on ROS.4-6

$$IO_4^- + 2H^+ \to IO_3^- + H_2O$$
 (S3)

$$O^{\bullet -} + H^+ \to HO^{\bullet}$$
 (S4)

$$3IO_4^- + 2OH^- \rightarrow 3IO_3^- + 2O_2^{\bullet-} + 2H_2O$$
 (S5)

$$2O_2^{\bullet -} + 2H_2O \rightarrow {}^1O_2 + H_2O_2 + 2OH^-$$
 (S6)

Effect of initial pH on RB5 degradation

The pH of the solution plays a vital role in the Cu(II)/SPI system. The pH-dependent catalytic performance of the Cu(II)/SPI system was systematically investigated through RB5 degradation experiments across a pH spectrum from 3 to 11, as presented in Fig. S2(c). Kinetic analysis (Table S1) revealed that the degradation process followed pseudo-first-order kinetics under all tested conditions. Notably, the system exhibited severely compromised catalytic activity under strongly acidic conditions (pH 3), achieving merely 6.05% RB5 removal after 120 minutes of treatment with a corresponding k_{obs} value of 0.0007 min⁻¹. This may be because the contaminant molecule has the same surface charge as Cu(II)/SPI, and a repulsion occurs. In general, contaminant molecules may have different surface charges at different solution pH. On the other hand, the surface properties of the oxidants and catalysts used are also highly dependent on the pH of the solution. Experiments have found that the point of zero charge (pzc) of RB5 is approximately between 3-4 (3.5). When the pH value of the solution is less than pHpzc, RB5 is positively charged; When the pH of the solution is greater than pHpzc, RB5 is negatively charged. When the pH value of the solution is 3, Cu(II) and SPI are positively charged on the surface, and RB5 is also positively charged, which leads to repulsion and hinders the degradation of RB5 in the system. The RB5 degradation in weak acid (pH=5) and partial neutral (pH=6.5) environments

were 92.39% and 91.34%, respectively, higher than in strongly acidic environments (pH=3). In an alkaline environment (pH=9, 11), the removal of RB5 was reduced by 10-20% in 120 minutes compared to weak acid and partial neutral environment. This is because when the pH value of the solution is greater than 3, Cu(II) and SPI have a positive charge, and the RB5 molecule has a negative charge at this time, and the opposite charges attract each other, which can better degrade the pollutants. When the pH of the solution is too high, there will be excess OH⁻ and Cu(II) in the solution to form a Cu(OH)₂ precipitate. This results in a decrease in Cu(II), insufficient activation capacity for SPI, and a decrease in the amount of ROS generated, which in turn leads to a reduction in the final removal rate.^{8,9}

Effect of initial RB5 concentration on RB5 degradation

The degradation performance of RB5 under different initial RB5 concentrations was systematically investigated, as depicted in Fig. S2(d). Experimental results revealed that following a 120-minute treatment period, the elimination percentages showed concentration-dependent characteristics: 93.53% at 25 μ M, 92.39% at 50 μ M, 91.66% at 75 μ M, 88.45% at 100 μ M, and 79.41% when the concentration reached 150 μ M. This inverse correlation between initial pollutant concentration and degradation efficiency suggests potential mass transfer limitations at elevated concentrations. This demonstrates that the degradation efficiency of the Cu(II)/SPI system on RB5 diminishes as the initial concentration of RB5 increases.

Text S4. Mechanism analysis

Drawing upon the outcomes of the free radical quenching experiments, a more indepth analysis of the potential degradation pathways within the system was subsequently carried out. •OH and ${}^{1}O_{2}$, as common ROS, exhibited a significant contribution to RB5 degradation in the system. Due to its strong oxidative property, •OH was able to non-selectively attack multiple functional groups in the RB5 molecule, leading to the rapid degradation of RB5. ${}^{1}O_{2}$, on the other hand, through its unique energy transfer mechanism, was able to effectively disrupt the conjugation system in the RB5 molecular structure, further promoting the decolorization and mineralization of RB5. It was shown that Cu(II) and ${\rm IO_4}^-$ could form a reactive complex under acidic conditions. When the complex decomposed, Cu(II) was oxidized to Cu(III), ${\rm IO_4}^-$ was reduced to ${\rm IO_3}^-$, and reactive oxygen species (•O) was released. Then •O was further converted to •OH by reaction with H₂O. In addition, Cu(III) can react with H₂O to regenerate Cu(II) with additional release of •OH (Eqs. S7-S11). ${}^{10-12}$

IO₃•and IO₄•as reactive iodine species played equally important roles in the Cu(II)/PI system. These iodine species with high oxidation potentials not only directly oxidized the RB5 molecule, but also triggered a series of chain reactions by reacting with the sites of higher electron cloud density in the RB5 molecule. Part of IO₄⁻ may decompose directly to form IO₃•, and the IO₃• and •O generated by the reaction may further participate in the oxidation reaction (Eqn. S12).¹³⁻¹⁵

$$CuSO_4 \cdot 5H_2O \rightarrow Cu^{2+} + SO_4^{2-} + 5H_2O$$
 (S7)

$$Cu^{2+} + IO_4^- + nH_2O \rightarrow [Cu(IO_4)(H_2O)n]^{P-}$$
 (S8)

$$[Cu(IO_4)(H_2O)n]^- + 2H^+ \to Cu^{3+} + IO_3^- + \bullet O + (n+1)H_2O$$
 (S9)

$$\bullet O + H_2O \to 2 \bullet OH \tag{S10}$$

$$Cu^{3+} + H_2O \to Cu^{2+} + \bullet OH + H^+$$
 (S11)

$$IO_4^- \to IO_3 \bullet^- + \bullet O$$
 (S12)

Figures

Fig. S1

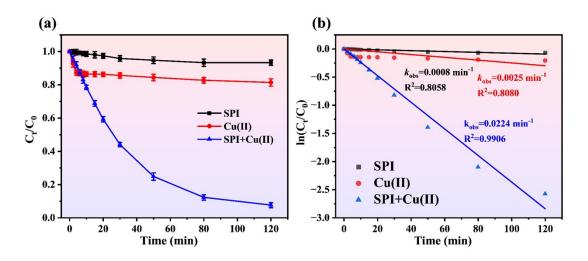


Fig. S1 (a) Comparison plot of degradation of RB5 by systems. Conditions: [Cu(II)] = 1 g L⁻¹, [SPI] = 50 μ M, [RB5] = 50 μ M, [pH] = 6.50, (b) kinetics of RB5 degradation by different systems.

Fig. S2

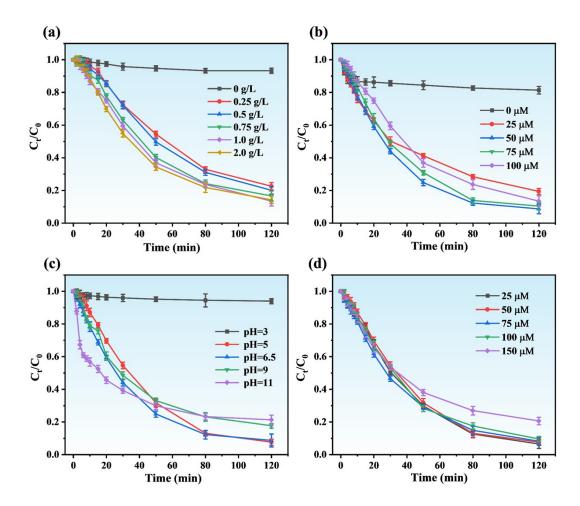


Fig. S2 (a) Effect of Cu(II) concentration on RB5 degradation (conditions: [Cu(II)] = 0-2 g L⁻¹, [SPI] = 100 μM, [RB5] = 50 μM, [pH] = 6.50), (b) effect of SPI concentration on RB5 degradation (conditions: [Cu(II)] = 1 g L⁻¹, [SPI] = 0-100 μM, [RB5] = 50 μM, [pH] = 6.50), (c) effect of initial pH on RB5 degradation (conditions: [Cu(II)] = 1 g L⁻¹, [SPI] = 50 μM, [RB5] = 50 μM, [pH] = 3.00-11.00), (d) effect of the concentration of RB5 on the degradation of RB5 (conditions: [Cu(II)] = 1 g L⁻¹, [SPI] = 50 μM, [RB5] = 25-150 μM, [pH] = 5.00).

Fig. S3

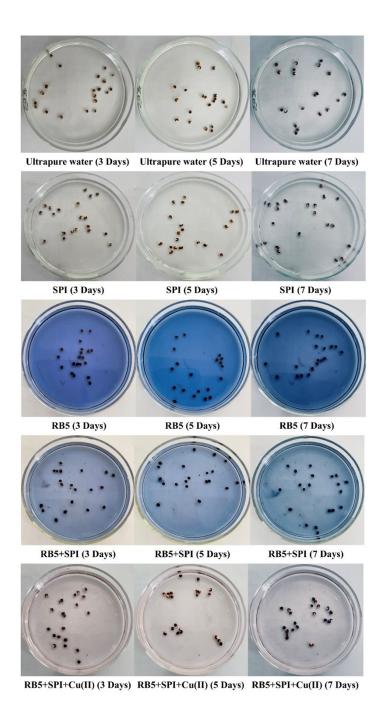


Fig. S3 Phytotoxicity test for RB5 degradation by Cu(II)/SPI system (Ultrapure water, 1 mM of SPI, 50 μ M of RB5, 1 mM of SPI+50 μ M of RB5, 1 mM of SPI+50 μ M of RB5+1 g L-1 of Cu(II))

Tables

Table S1

Table S1. Kinetics of RB5 degradation by Cu(II)/SPI system under different conditions

Cu(II)	SPI	II	RB5	Degradation kinetic	k _{obs}	D?	
(g L-1)	(µM)	pН	(μM)	equations	(min ⁻¹)	\mathbb{R}^2	
0	100	6.5	50	$-\ln(C_t/C_0)=0.0008t$	0.0008	0.9058	
0.25	100	6.5	50	$-\ln(C_t/C_0)=0.0125t$	0.0125	0.9859	
0.5	100	6.5	50	$-\ln(C_t/C_0)=0.0135t$	0.0135	0.9884	
0.75	100	6.5	50	$-\ln(C_t/C_0)=0.0159t$	0.0159	0.9869	
1.0	100	6.5	50	$-\ln(C_t/C_0)=0.0173t$	0.0173	0.9950	
2.0	100	6.5	50	$-\ln(C_t/C_0)=0.0176t$	0.0176	0.9878	
1.0	0	6.5	50	$-\ln(C_t/C_0)=0.0025t$	0.0025	0.8080	
1.0	25	6.5	50	$-\ln(C_t/C_0)=0.0153t$	0.0153	0.9695	
1.0	50	6.5	50	$-\ln(C_t/C_0)=0.0224t$	0.0224	0.9906	
1.0	75	6.5	50	$-\ln(C_t/C_0)=0.0211t$	0.0211	0.9839	
1.0	50	3	50	$-\ln(C_t/C_0)=0.0007t$	0.0007	0.8133	
1.0	50	5	50	$-\ln(C_t/C_0)=0.0230t$	0.0230	0.9817	
1.0	50	9	50	$-\ln(C_t/C_0)=0.0168t$	0.0168	0.9657	
1.0	50	11	50	$-\ln(C_t/C_0)=0.0172t$	0.0172	0.8326	
1.0	50	5	25	$-\ln(C_t/C_0)=0.0237t$	0.0237	0.9958	
1.0	50	5	75	$-\ln(C_t/C_0)=0.0222t$	0.0222	0.9944	
1.0	50	5	100	$-\ln(C_t/C_0)=0.0207t$	0.0207	0.9918	
1.0	50	5	150	$-\ln(C_t/C_0)=0.0151t$	0.0151	0.9725	

Table S2

Table S2. Independent variables and levels

Indonendent vewichles	Cymhola	Levels		
Independent variables	Symbols	-1	0	+1
SPI (μM)	A	25	50	75
$CuSO_4$ (g L^{-1})	В	0.75	1	1.25
pН	C	4	5	6

Table S3. Actual and predicted dependent variable (RB5) values for each experiment

Run	A	n	C	RB5 removal(%)		
		В	C	Actual value	Predicted value	
1	0	1	-1	87.23	87.41	
2	-1	-1	0	81.93	81.80	
3	0	0	0	92.66	92.03	
4	0	-1	-1	82.20	82.33	
5	0	0	0	92.26	92.03	
6	0	0	0	91.07	92.03	
7	1	0	1	88.82	88.82	
8	0	-1	1	85.64	85.44	
9	1	1	0	89.09	89.22	
10	1	0	-1	87.50	87.16	
11	1	-1	0	84.72	84.91	
12	-1	1	0	85.38	85.18	
13	0	0	0	91.73	92.03	
14	0	1	1	88.16	88.03	
15	0	0	0	92.40	92.03	
16	-1	0	1	85.11	85.44	
17	-1	0	-1	83.40	83.39	

Table S4. ANOVA test of the response function

Table S4

Source	Sum of Squares	df	Mean Square	F-value	p-value	
Model	203.90	9	22.66	77.76	< 0.0001	significant
A-SPI	25.57	1	25.57	87.76	< 0.0001	
B-CuSO ₄	29.50	1	29.50	101.23	< 0.0001	
С-рН	6.87	1	6.87	23.59	0.0018	
AB	0.2148	1	0.2148	0.7374	0.4189	
AC	0.0394	1	0.0394	0.1352	0.7239	
BC	1.58	1	1.58	5.43	0.0526	
A^2	42.45	1	42.45	145.70	< 0.0001	
B^2	53.74	1	53.74	184.43	< 0.0001	
C^2	29.47	1	29.47	101.14	< 0.0001	
Residual	2.04	7	0.2914			
Lack of Fit	0.4474	3	0.1491	0.3746	0.7770	
Pure Error	1.59	4	0.3980			
Cor Total	205.94	16				

Others: R^2 =0.9901, Adjusted R^2 =0.9774, Predicted R^2 =0.9532, Adeq Precision=24.6958.

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